Effect of purity of Ti on growth behaviour of Ti suicide formed in bulk Ti/Si diffusion couple

Shimozaki T, Chikumaru K, Wakamatsu Y, Onishi M. Nippon Kinzoku Gakkaishi/Journal of the Japan Institute of Metals 1996; 60(1):29-36

ARTICLE IDENTIFIERS

DOI: 10.2320/jinstmet1952.60.1_29 PMID: unavailable PMCID: not available

JOURNAL IDENTIFIERS

LCCN: not available pISSN: 0021-4876 eISSN: not available OCLC ID: not available CONS ID: not available US National Library of Medicine ID: not available

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